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thin solid films

Contents

Preface ix

Sponsors xi

Deposition

Relation between structural and physical properties in magnetic and superconducting superlattices 1
Y. Bruynseraede, K. Temst, R. Schad, C.D. Potter, P. Belien, G. Verbanck, G. Gladyszewski, J. Barnas, M. Baert, V.V. Metlushko, M.J. Van Bael, V.V. Moshchalkov (Leuven, Belgium)

Conversion electron Mössbauer spectroscopy study of iron disilicide films grown by MBE 8
M. Fanciulli, C. Rosenblad, G. Weyer (Aarhus, Denmark), H. Von Känel, N. Onda (Zürich, Switzerland)

First stages of platinum electroless deposition on silicon(100) from hydrogen fluoride solutions studied by AFM 12
P. Gorostiza, J. Servat, J.R. Morante, F. Sanz (Barcelona, Spain)

Structure of laser-deposited metallic alloys and multilayers 18
H.-U. Krebs, O. Bremert, Y. Luo, S. Fähler, M. Störmer (Göttingen, Germany)

Stresses, Mechanical Properties, Electromigration

Study of the mechanical and microstructural state of platinum thin films 22
V. Branger, V. Pelosin, K.F. Badawi, Ph. Goudeau (Poitiers, France)

Residual stresses influence on the structural evolution of Cu–Mo solid solutions studied by X-ray diffraction 25
Ph. Goudeau, J. Mimault, Th. Girardeau, K. Reklaoui, O. Proux, V. Branger (Poitiers, France)

Microstructure and residual stresses in (111) Au/Ni multilayers 29
S. Labat, B. Pichaud, O. Thomas, C. Alfonso, A. Charaï (Marseille, France), L. Barrallier (Aix en Provence, France), B. Gilles, A. Marty (Grenoble, France)

Structure Determination

Structural characterisation of multilayer films 35
A.K. Petford-Long (Oxford, UK)

Profile analysis of thin film X-ray diffraction peaks 40
L. Bimbault, K.F. Badawi, Ph. Goudeau, V. Branger, N. Durand (Poitiers, France)

In-situ spectroscopic ellipsometry for monitoring the Ti–Si multilayers during growth and annealing 44
S. Logothetidis, I. Alexandrou, N. Vouroutzis (Thessaloniki, Greece)

Reactions, Structural Evolution

Metallic multilayers and hydrogen 48
A. Weidinger, D. Nagengast, Ch. Rehm, F. Klose, B. Pietzak (Berlin, Germany)

The influence of the ion flux density on the properties of molybdenum films deposited from the vapour phase under simultaneous argon ion irradiation 54
W. Ensinger (Augsburg, Germany)

Growth, morphology and annealing of thin Co layers on Au/mica 58
T.H. Gentner, F. Scheurer, T. Detzel, J.P. Bucher (Strasbourg, France)

Study on the crystallization of nickel films prepared by the ion beam and vapour deposition method 61
Y. Murakami, N. Kuratani, O. Imai, K. Ogata (Kyoto, Japan)

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Structure, magnetism and thermal stability of Fe–Al_2O_3 multilayers 64
O. Lenoble, J.F. Bobo, L. Hennet, H. Fischer, Ph. Bauer, M. Piecuch (Vandœuvre, France)

PAC and CEMS study of ion-irradiated Ag/Fe and In/Fe layers 69
M. Neubauer, K.P. Lieb, P. Schaaf, M. Uhrmacher (Göttingen, Germany)

Amorphization, Amorphous Phases

Multilayers—a way to prepare metastable phases by multiple interface reactions 73
A. Siber, D. Massinger, Th. Koch, P. Ziemann (Konstanz, Germany)

The influence of composition on the crystallisation kinetics of relaxed SbGe films 78
M.C. Morilla, C.N. Afonso (Madrid, Spain), A.K. Petford-Long, R.C. Doole (Oxford, UK)

Influence of deposition conditions and ion irradiation on thin films of amorphous Cu–Zr superconductors 82
N. Karpe (Stockholm, Sweden), J. Bøttiger, J.P. Krog (Aarhus, Denmark), A. Nordström, Ö. Rapp (Stockholm, Sweden)

Erbium silicide films on (100) silicon, grown in high vacuum. Fabrication and properties 87
G. Kaltsas, A. Travlos, N. Salamouras, A.G. Nassiopoulos, P. Revva (Athens, Greece), A. Traverse (Orsay, France)

Thin-film Magnetism

Thickness-dependent in-plane magnetic anisotropy in epitaxial Fe films on GaAs substrates 91
M. Gester, C. Daboo, R.J. Hicken, S.J. Gray, J.A.C. Bland (Cambridge, UK)

Magnetic circular dichroism of Fe/Pd(100) ultrathin films 95
X. Le Cann, C. Boeglin (Strasbourg, France), K. Hricovini (Orsay, France), B. Carrière (Strasbourg, France)

Comparison of magnetism and morphology of ultrathin Fe films on Cu(100) and Cu_3Au(100) 99
M.-T. Lin, J. Shen, J. Giergiel, W. Kuch, H. Jenniches, M. Klaua, C.M. Schneider, J. Kirschner (Halle, Germany)

C(2×2) ferrimagnetic order versus P(1×1) ferromagnetic order in V, Cr, Mn monolayers on Fe(001) 103
A. Vega, S. Bouarab (Valladolid, Spain), H. Dreyssé, C. Demangeat (Strasbourg, France)

Giant Magnetoresistance

Giant magnetoresistance and microstructure in Cr–Fe and Cu–Co heterogeneous alloys 106
K. Takanashi, J. Park, T. Sugawara, K. Hono (Sendai, Japan), A. Goto, H. Yasuoka (Tokyo, Japan), H. Fujimori (Sendai, Japan)

Irreversibility in giant magnetoresistance and its relation to magnetic substructure 111
D.B. Jardine, M.J. Hall, R.E. Somekh, J.E. Evetts (Cambridge, UK)

Structure and oscillatory magnetoresistance of Co(hcp)/Cu sandwiches 115
N. Persat, A. Dinia, J.P. Jay, C. Mény, P. Panissod (Strasbourg, France)

Electronic Structure, Electronic Transport, General Magnetism

Magnetic flux pinning and microstructure, a special case: *a*-axis oriented $EuBa_2Cu_3O_7/PrBa_2Cu_3O_7$ superconducting superlattices ... 119
J.I. Martín, M. Vélez, J.L. Vicent (Madrid, Spain)

Conductivity of thin antimony films at low temperatures 125
B.A. Hermann, I. Didschuns, P. Haier, M. Köpp, N. Esser, U. Resch-Esser, W. Richter, K. Lüders (Berlin, Germany)

Microstructural studies and magneto-optic properties of Co/Au multilayers epitaxially grown on MoS_2 substrates 129
M.J. Casanove, E. Snoeck, C. Penchenat, H. Ardhuin, R. Mamy, B. Raquet, M.D. Ortega, M. Goiran, A.R. Fert, J.-C. Ousset (Toulouse, France)

Crystallographic and electronic structure of Cu/Cr/Cu(001) sandwiches 133
P. Schieffer, D. Rouyer, C. Krembel, M.C. Hanf, D. Bolmont, G. Gewinner (Mulhouse, France)

MBE growth and characterisation of light rare-earth superlattices 137
R.C.C. Ward, M.R. Wells, C. Bryn-Jacobsen, R.A. Cowley, J.P. Goff (Oxford, UK), D.F. McMorrow (Roskilde, Denmark), J.A. Simpson (Oxford, UK)

Structure and Properties of Metallic Thin Films and Multilayers (Poster Session)

Optical and crystallographic properties of potassium-implanted tungsten 140
M. Afif, J.P. Girardeau-Montaut (Villeurbanne, France), A. Perez, N. Moncoffre, G. Marest (Lyon, France), S. Fayeulle (Ecully, France), J.M. Frigerio (Paris, France)

Segregation effect on grain-boundary diffusion in thin metallic films 144
A.N. Aleshin (Chernogolovka, Moscow District, Russia), B.S. Bokstein (Moscow, Russia), V.K. Egorov (Chernogolovka, Moscow District, Russia), P.V. Kurkin (Moscow, Russia)

Influence of interface roughness and quantum size effect on the giant magnetoresistance in magnetic layered structures 148
J. Barnaś, Y. Bruynseraede (Leuven, Belgium)

The influence of the argon pressure and substrate temperature on the structure of r.f.-sputtered CrNi(65:35), CrNi(50:50) and CrNi(20:80) thin films 152
M.I. Birjega, M. Alexe (Bucharest, Romania)

Perpendicular magnetic anisotropy in epitaxial Cu/Ni/Cu/Si (001) 155
H.E. Inglefield, G. Bochi, C.A. Ballentine, R.C. O'Handley, C.V. Thompson (Cambridge, MA, USA)

Investigation on metallurgical properties and electromigration in AlCu metallizations for VLSI applications 159
S. Dietrich, M. Schneegans (München, Germany), M. Moske, K. Samwer (Augsburg, Germany)

Synthesis of amorphous Zr–Cu alloys by magnetron co-sputtering 164
J. Dudonis, R. Bručas, A. Miniotas (Kaunas, Lithuania)

Influence of microstructure on residual stress in tungsten thin films analyzed by X-ray diffraction 168
N. Durand, K.F. Badawi, Ph. Goudeau (Poitiers, France)

Domain splitting in epitaxial Fe/GaAs(001) films during hard axis reversal 172
U. Ebels, M. Gester, C. Daboo, J.A.C. Bland (Cambridge, UK)

Thickness- and concentration-dependent crystal-to-amorphous transition of $Fe_{100-x}Zr_x$ in $Zr/Fe_{100-x}Zr_x/Zr$ trilayers 176
H. Geisler, U. Herr, T. Lorenz, K. Samwer (Augsburg, Germany)

Epitaxially grown Ag(001)/Fe(001) superlattices 180
G. Gladyszewski, K. Temst, R. Schad, P. Beliën, E. Kunnen, G. Verbanck, Y. Bruynseraede (Leuven, Belgium)

Monte Carlo simulation of non-specular X-ray scattering profiles from multilayered structures 184
G. Gladyszewski, Y. Bruynseraede (Leuven, Belgium)

X-ray diffraction study of the sub-structure modification induced by residual stresses during the deposition process of 304L stainless steel films 188
Ph. Goudeau, B. Boubeker, J.P. Eymery, V. Branger (Poitiers, France)

Iron silicide formation on hydrogenated amorphous silicon 191
P. Grunow, H. Paes, Jr., C. Gatts, W. Losch (Rio de Janeiro, Brazil)

The giant magnetoresistance and magnetisation of sputter deposited Co/Cu multilayers 195
M.J. Hall, E.D. Whitton, D.B. Jardine, R.E. Somekh, J.E. Evetts, J.A. Leake (Cambridge, UK)

Bilinear and biquadratic exchange coupling in epitaxial Fe/Cr/Fe/Ag/GaAs(100) structures 199
R.J. Hicken, C. Daboo, M. Gester, A.J.R. Ives, S.J. Gray, J.A.C. Bland (Cambridge, UK)

Texture and phase transformation of sputter-deposited metastable Ta films and Ta/Cu multilayers 203
R. Hoogeveen, M. Moske, H. Geisler, K. Samwer (Augsburg, Germany)

Crystallographic and magnetic investigations of the cobalt columns electrodeposited in the pores of anodic alumina 207
H.R. Khan, O. Loebich, G. Rauscher (Schwäbisch Gmünd, Germany)

Study of structural imperfections in sputtered Co/Cu multilayers 210
K.Y. Kok, J.A. Leake (Cambridge, UK)

Elaboration and characterization of Ti and TiN thin films and Ti/TiN multilayers for hard coating applications 213
S. Labdi, Ph. Houdy, P. Psyllaki, M. Jeandin (Evry, France)

Electrodeposition of metallic multilayers with modulated electric regimes 216
N. Lebbad (Saint Martin d'Hères, France), J. Voiron (Grenoble, France), B. Nguyen, E. Chainet (Saint Martin d'Hères, France)

Magnetization and magnetoresistance in granular AgCo films 220
T. Lorenz, M. Moske, H. Geisler, R.v. Helmolt, M. Weiß, K. Samwer (Augsburg, Germany)

Perpendicular magnetic anisotropy in Co_xPt_{1-x} alloy films 224
M. Maret, M.C. Cadeville, W. Staiger, E. Beaurepaire, R. Poinsot, A. Herr (Strasbourg, France)

Diffusion of charged impurities in graded-gap HgTe/CdTe superlattices 228
L.S. Monastyrsky (Lviv, Ukraine)

Magnetic and electrical characterizations of thin Ni–Fe and Ni–Fe–Mo films 231
A.-M. Nguyen (Gif sur Yvette, France), S. Cercelaru, G. Tremblay (Orsay, France), J.-C. Perron (Gif sur Yvette, France), P. Hesto (Orsay, France)

Non-equilibrium phase formation in ion-bombarded alloys 235
P.M. Ossi (Milano, Italy)

Surface topography of amorphous $Zr_{65.0}Al_{7.5}Cu_{27.5}$ alloy films around the glass transition—an in-situ UHV-STM study 240
B. Reinker, H. Geisler, M. Moske, K. Samwer (Augsburg, Germany)

Metal–insulator transition and giant magnetoresistance in $La_{1-x}MnO_{3-\delta}$ thin films and superlattices 244
S. Sundar Manoharan, M.S. Hegde, K.M. Satyalakshmi, V. Prasad, S.V. Subramanyam (Bangalore, India)

Effect of ion irradiation on the structure of Au/Ni multilayers 247
F. Tamisier, C. Jaouen, Ph. Guérin (Poitiers, France), G. Gladyszewski (Leuven, Belgium)

Mössbauer characterization of FeN thin films prepared by reactive evaporation 251
M. Vergnat, Ph. Bauer, H. Chatbi, G. Marchal (Vandœuvre-lès-Nancy, France)

Role of point defects on the optical properties of Pd-based Hume–Rothery alloys 254
W.T. Wu, P.E. Schmid, M. Posternak, F. Lévy (Lausanne, Switzerland)

Effects of short-range ordering on interdiffusion in Ag/Au epitaxial multilayers 258
F.-L. Yang, A.L. Greer, R.E. Somekh (Cambridge, UK)

Epitaxial fcc Fe–Co alloy films on Cu(001) 262
M. Zharnikov, A. Dittschar, W. Kuch, K. Meinel, C.M. Schneider, J. Kirschner (Halle, Germany)

Surface structure characterization by photoelectron holography 266
M. Zharnikov, M. Weinelt, P. Zebisch, H.-P. Steinrück (Garching, Germany)

Author Index of Volume 275 271

Subject Index of Volume 275 273

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